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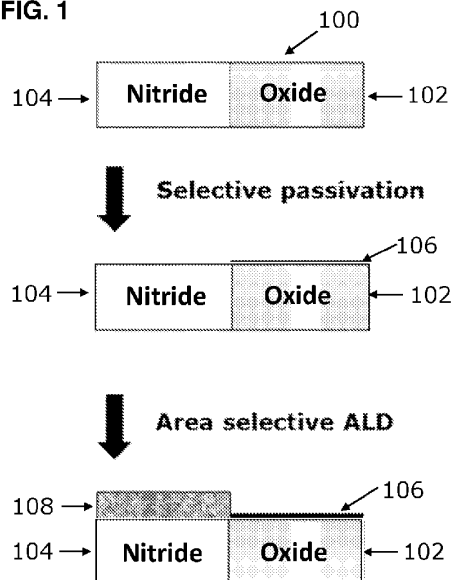
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(54) Title: SELECTIVE DEPOSITION OF SILICON CONTAINING FILMS UTILIZING ORGANOAMINOPOLYSILOXANES
AND ORGANOAMINOPOLYSILAZANES

FIG. 1



(57) Abstract: A method for selectively passivating a surface of a substrate, wherein the surface of the substrate includes at least a first surface comprising a dielectric and at least a second surface comprising another material. The method includes the step of exposing the first and second surfaces to at least one organoaminopolysiloxane or organoaminopolysilazane wherein the organoaminopolysiloxane or organoaminopolysilazane selectively reacts with the dielectric to passivate the first surface thereby leaving the second surface substantially unreacted.

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